



US00D761996S

(12) **United States Design Patent**
Nguyen(10) **Patent No.:** **US D761,996 S**
(45) **Date of Patent:** ** Jul. 19, 2016(54) **ORIGAMI SKIRT**(71) Applicant: **Uyen-Phuong Ngoc Nguyen**, New York, NY (US)(72) Inventor: **Uyen-Phuong Ngoc Nguyen**, New York, NY (US)(**) Term: **14 Years**(21) Appl. No.: **29/521,576**(22) Filed: **Mar. 25, 2015**(51) LOC (10) Cl. **26-99**

(52) U.S. Cl.

USPC **D26/118**(58) **Field of Classification Search**

USPC D26/24, 26, 51, 56, 54, 61, 72–91, 113, D26/118, 130–134; D11/131, 131.1, 157,

D11/141, 142

CPC F21S 8/035; F21S 8/00; F21S 2/005; F21S 6/002

See application file for complete search history.

(56)

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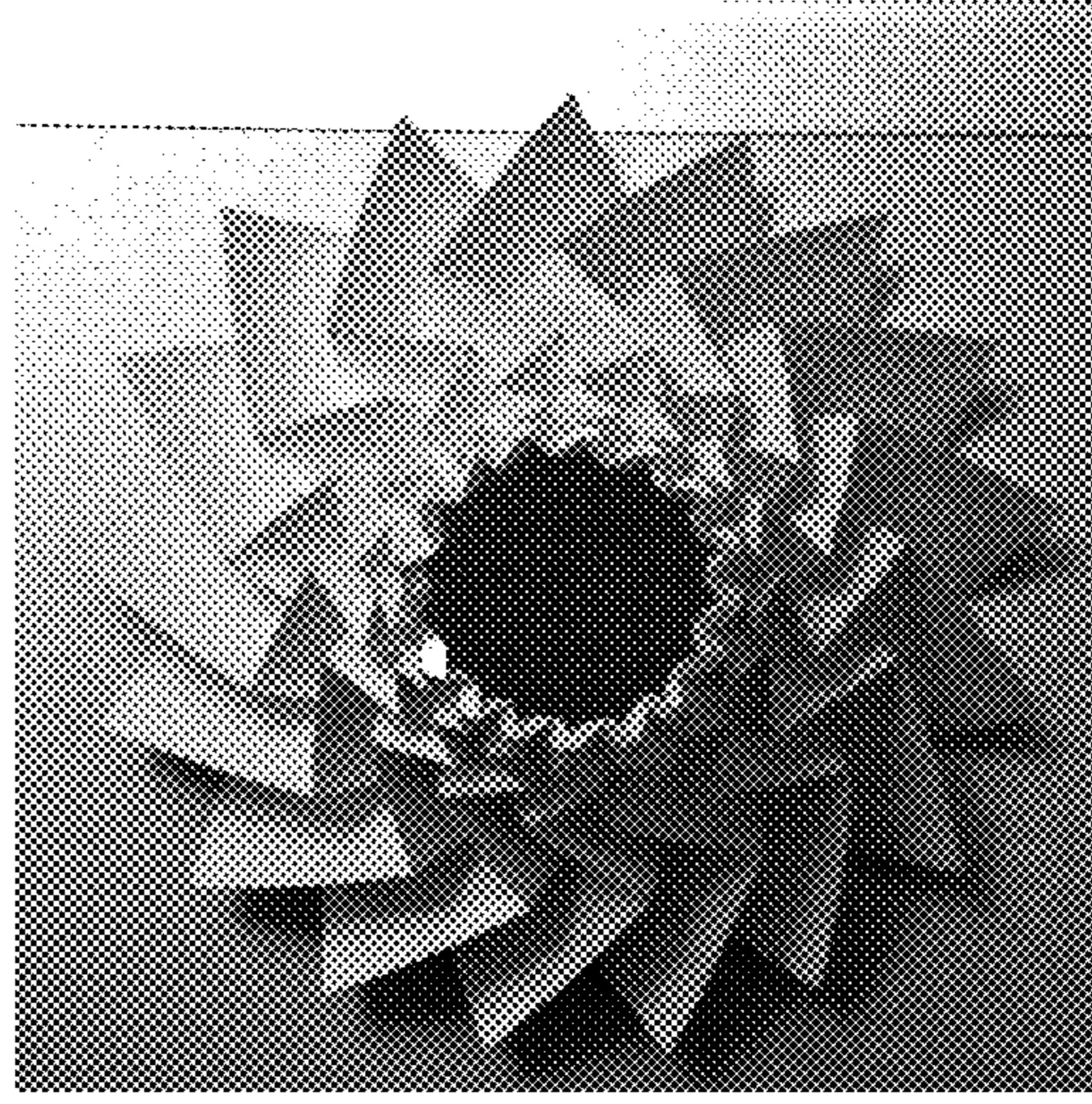
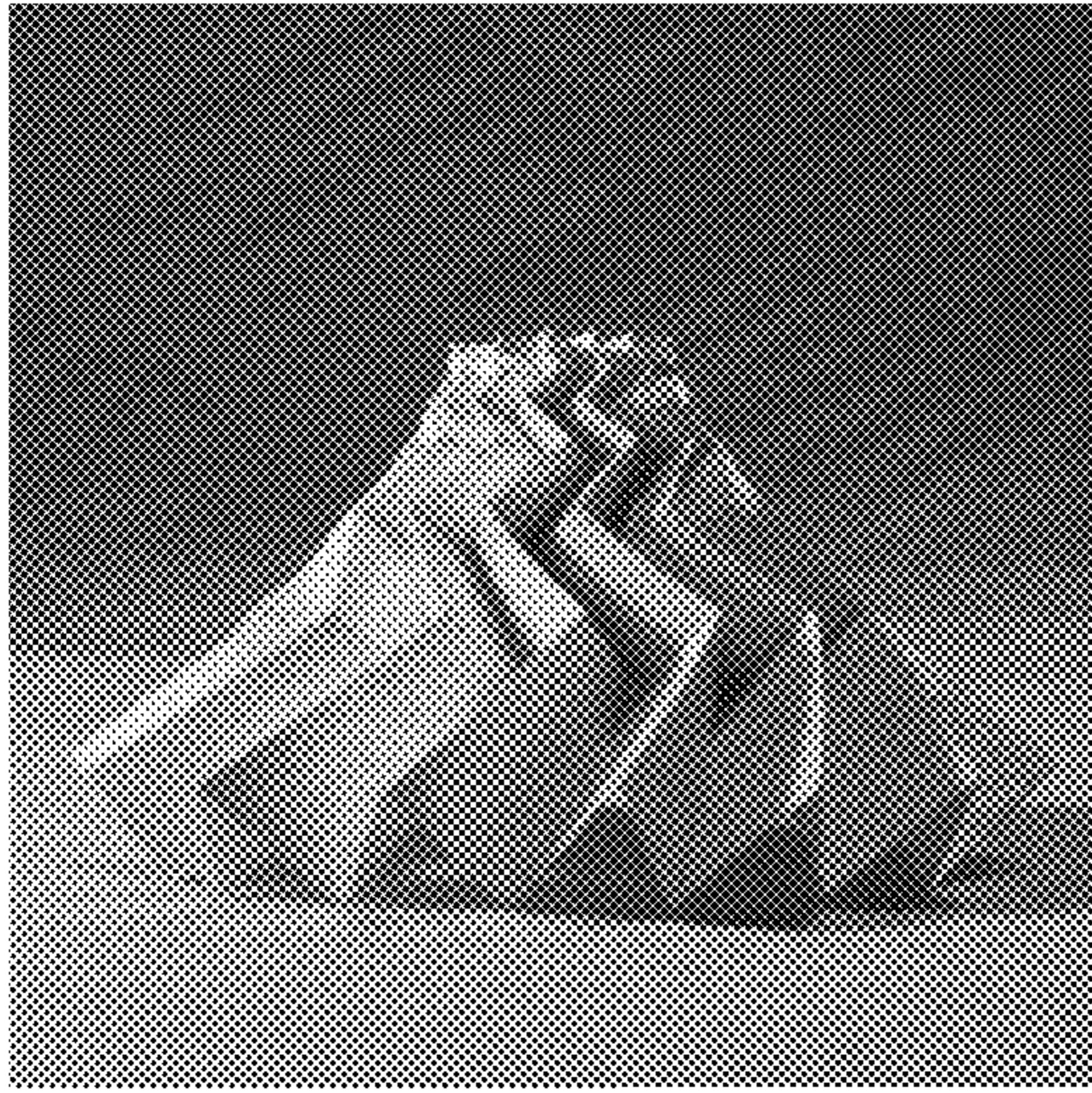
* cited by examiner

Primary Examiner — Brian N Vinson(57) **CLAIM**

The ornamental design for an origami skirt, as shown.

DESCRIPTION

FIG. 1 is a front elevational view of the origami skirt; and, FIG. 2 is a top plan view thereof.

1 Claim, 2 Drawing Sheets

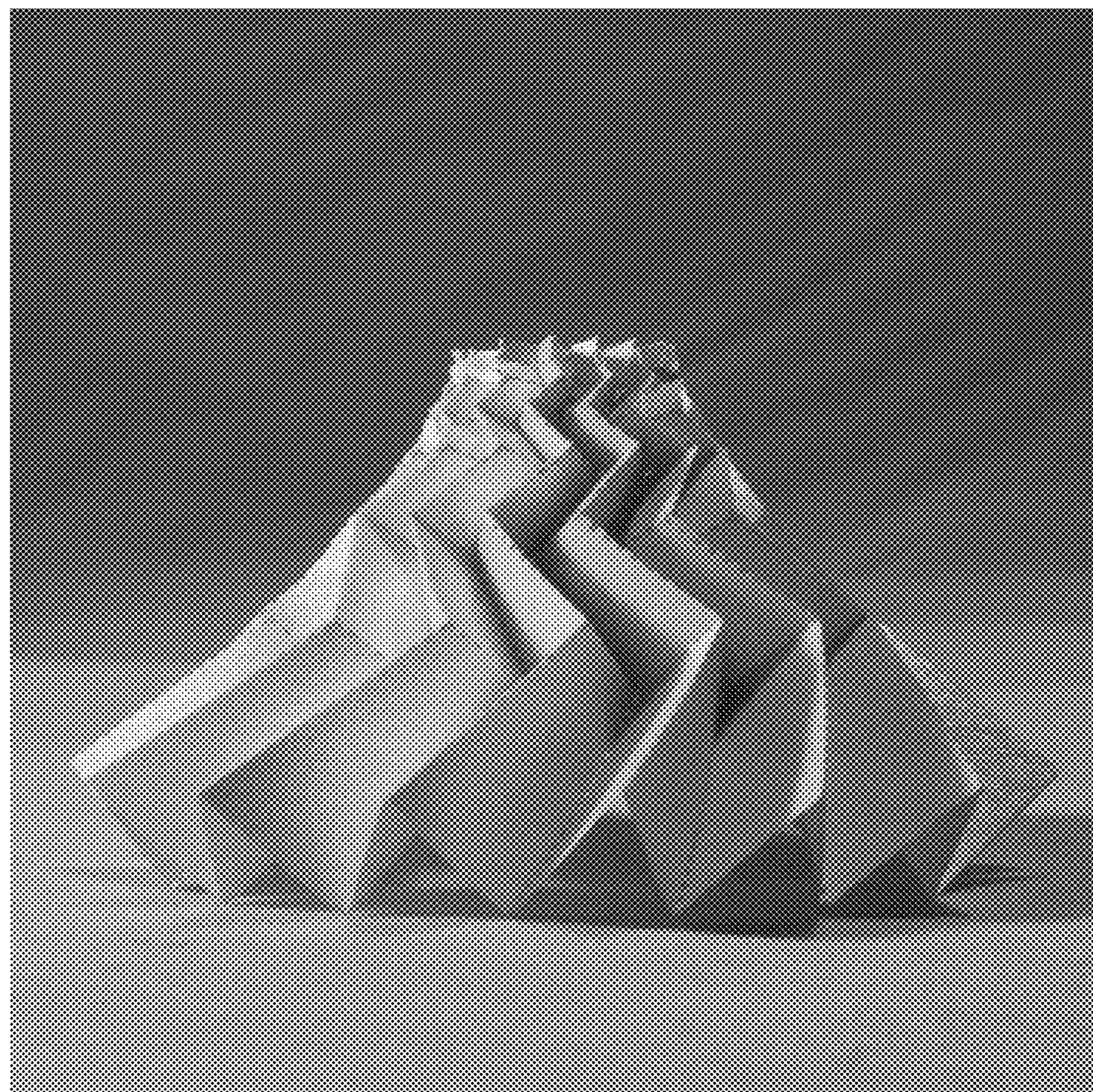


Fig. 1

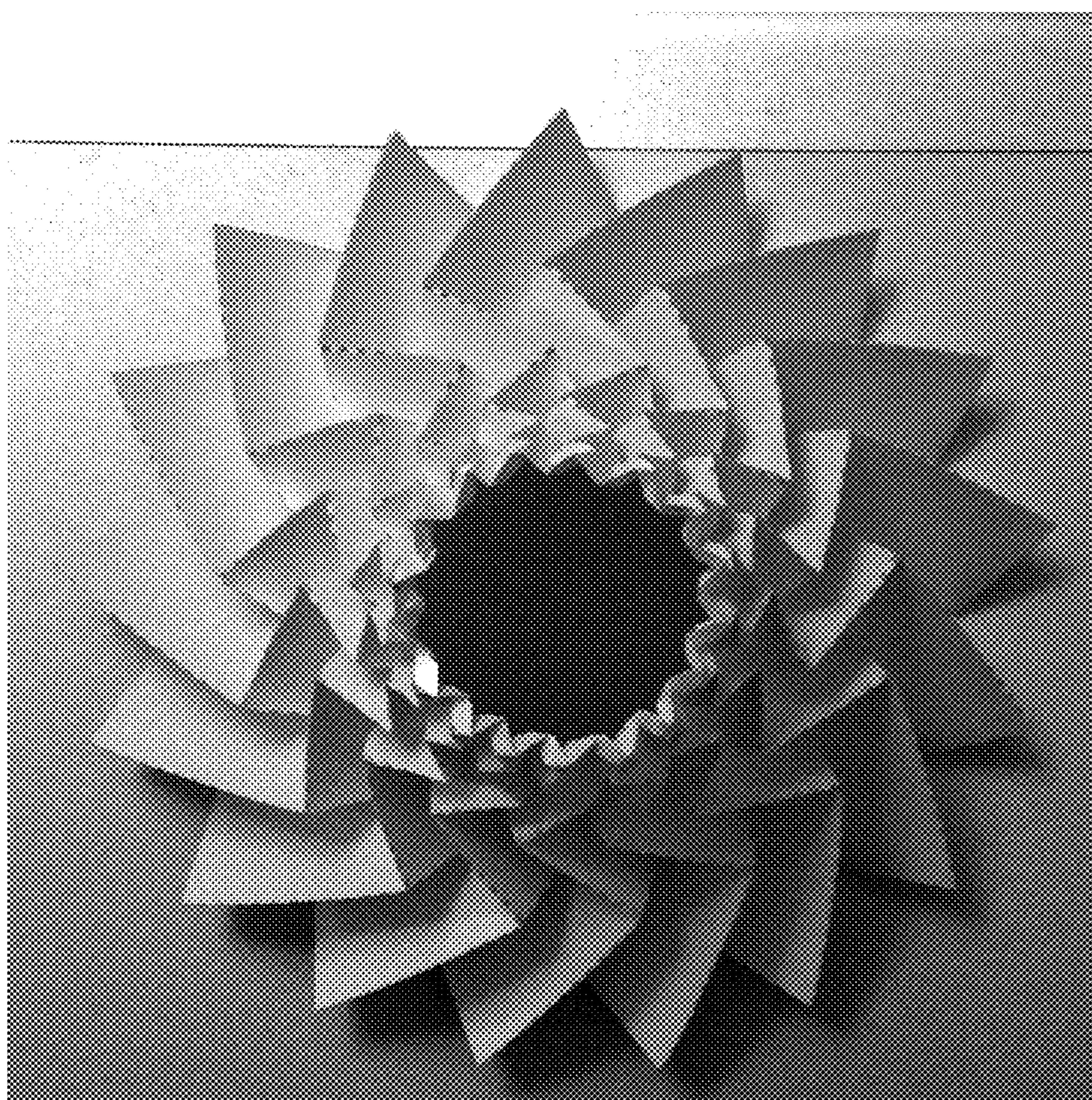


Fig. 2